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**PATENT APPLICATION**

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

1722

In re the Application of

Attn: OIPE

Masahiro SAKURADA et al.

Application No.: 10/538,878

Docket No.: 124231

Filed: June 14, 2005

For: METHOD OF PRODUCING P-DOPED SILICON SINGLE CRYSTAL AND P-DOPED N-TYPE SILICON SINGLE CRYSTAL WAFER

**REQUEST FOR CORRECTION OF PALM RECORDS**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Attached is a photocopy of the original filing receipt on which errors have been corrected in red. These errors are being brought to the attention of the Patent and Trademark Office so that it may correct its records. The originally filed application data sheet is attached.

Respectfully submitted,

William P. Berridge  
Registration No. 30,024

Jesse O. Collier  
Registration No. 53,839

WPB:JOC/mps

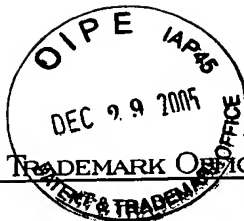
Date: December 29, 2005

**OLIFF & BERRIDGE, PLC**  
**P.O. Box 19928**  
**Alexandria, Virginia 22320**  
**Telephone: (703) 836-6400**

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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/538,878	06/14/2005	1722	1300	124231	4	28	2

CONFIRMATION NO. 8834

25944  
 OLIFF & BERRIDGE, PLC  
 P.O. BOX 19928  
 ALEXANDRIA, VA 22320

DEC 15 2005

## FILING RECEIPT



\*OC000000017601533\*

Date Mailed: 12/12/2005

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please mail to the Commissioner for Patents P.O. Box 1450 Alexandria Va 22313-1450. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

## Applicant(s)

Masahiro Sakurada, Fukushima, JAPAN;  
 Izumi Fusegawa, Fukushima, JAPAN;

**Power of Attorney:** The patent practitioners associated with Customer Number 25944.

## Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP03/16794 12/25/2003

## Foreign Applications

JAPAN 2003-10436 01/17/2003

**Projected Publication Date:** 03/16/2006

**Non-Publication Request:** No

**Early Publication Request:** No

## Title

METHOD OF

Process for producing p-doped silicon single crystal and p-doped n-type silicon single crystal wafer



Preliminary Class

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